

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/743,830	12/24/2003	Hideo Tsuchiya	247185US2SRD	1135	
22850 7590 07/03/2007 OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C.			EXAMINER		
1940 DUKE ST	1940 DUKE STREET			NGUYEN, SANG H	
ALEXANDRIA	A, VA 22314	•	ART UNIT	PAPER NUMBER	
				3	
·					
			NOTIFICATION DATE	DELIVERY MODE	
		•	07/03/2007	ELECTRONIC	

# Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

patentdocket@oblon.com oblonpat@oblon.com jgardner@oblon.com

				سنرا			
		Application No.	Applicant(s)				
		10/743,830	TSUCHIYA ET AL.				
	Office Action Summary	Examiner	Art Unit				
		Sang Nguyen	2886				
Period for	The MAILING DATE of this communication app Reply	ears on the cover sheet with the	correspondence address				
WHICH - Extens after S - If NO p - Failure Any re	PRTENED STATUTORY PERIOD FOR REPLY HEVER IS LONGER, FROM THE MAILING DATE of time may be available under the provisions of 37 CFR 1.13 (X 6) MONTHS from the mailing date of this communication. Period for reply is specified above, the maximum statutory period to reply within the set or extended period for reply will, by statute, ply received by the Office later than three months after the mailing patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATIO 36(a). In no event, however, may a reply be ti vill apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONI	N. mely filed in the mailing date of this communication. ED (35 U.S.C. § 133).				
Status							
1)⊠ F	Responsive to communication(s) filed on <u>24 De</u>	ecember 2003.	·				
2a) <u> </u>	This action is <b>FINAL</b> . 2b)⊠ This action is non-final.						
· -	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
C	closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 4	53 O.G. 213.				
Dispositio	n of Claims	•					
4) 🛛 (	Claim(s) <u>1-17</u> is/are pending in the application.						
•	a) Of the above claim(s) is/are withdraw	·					
5) 🔲 (	Claim(s) is/are allowed.						
6)⊠ (	Claim(s) <u>1-17</u> is/are rejected.						
7) 🗌 (	Claim(s) is/are objected to.						
8) 🗌 (	Claim(s) are subject to restriction and/o	r election requirement.					
Application	on Papers						
9)□ ⊤	he specification is objected to by the Examine	r.					
10) 🔲 T	he drawing(s) filed on is/are: a) _ acc	epted or b) objected to by the	Examiner.				
,	Applicant may not request that any objection to the	drawing(s) be held in abeyance. Se	e 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) 🔲 T	he oath or declaration is objected to by the Ex	aminer. Note the attached Office	e Action or form PTO-152.				
Priority ur	nder 35 U.S.C. § 119						
, a)⊠	cknowledgment is made of a claim for foreign ☑ All b) ☐ Some * c) ☐ None of:		a)-(d) or (f).				
	1.⊠ Certified copies of the priority document						
	2. Certified copies of the priority document						
•	3. Copies of the certified copies of the prior		ed in this National Stage				
* \$4	application from the International Bureau ee the attached detailed Office action for a list	·	ed .				
	ce the attached detailed office action for a list	or the defining copies not receiv	cu.				
Attachment(	s)		•				
	of References Cited (PTO-892)	4) Interview Summar					
3) 🔯 Inform	of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO/SB/08) No(s)/Mail Date 4/05; 3/04; 12/03.	Paper No(s)/Mail D  5) Notice of Informal  6) Other:					

Art Unit: 2886

### **DETAILED ACTION**

# **Priority**

Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

#### Information Disclosure Statement

The information disclosure statement (IDS) submitted on 04/28/05, 03/16/04, and 12/24/03 has been entered. The submission is in compliance with the provisions of 37 CFR 1.97. Accordingly, the information disclosure statement is being considered by the examiner.

## **Drawings**

The drawings are objected to under 37 CFR 1.83(a). The drawings must show every feature of the invention specified in the claims. Therefore, the "a sample having a first and second inspection regions" in claim 1; and the "a first inspection region on which a first pattern is formed and a second inspection region on which a second pattern is formed", the "a position recognizing unit", the "a signal output unit", the "a control unit" in claim 9 must be shown or the feature(s) canceled from the claim(s). No new matter should be entered.

Corrected drawing sheets in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. Any amended replacement drawing sheet should include all of the figures appearing on the immediate prior version of the sheet, even if only one figure is being amended. The figure or figure number of an amended drawing should not be labeled as "amended." If a drawing figure

Art Unit: 2886

is to be canceled, the appropriate figure must be removed from the replacement sheet, and where necessary, the remaining figures must be renumbered and appropriate changes made to the brief description of the several views of the drawings for consistency. Additional replacement sheets may be necessary to show the renumbering of the remaining figures. Each drawing sheet submitted after the filing date of an application must be labeled in the top margin as either "Replacement Sheet" or "New Sheet" pursuant to 37 CFR 1.121(d). If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-17 are rejected under 35 U.S.C. 102(b) as being anticipated by Isomuara et al (U.S. Patent No. 6,285783).

Regarding claim 1; Isomura et al discloses a pattern inspecting method, comprising:

preparing a sample (5 of figure 1) having a first and a second inspection regions (**A** of figure 1 or **F** of figure 22) and an imaging device (e.g., image sensor [57 of figure 1) having a plurality of pixels (col.2 lines 58-67 and col.3 lines 1-27);

Art Unit: 2886

scanning (56 of figure 1) the first inspection region (figures 1, 22, and 23A-23B) to a first direction (e.g., X direction in figure 23B) using the imaging device (57 of figure1) to obtain a first measurement pattern (e.g., A of figure 1) representing at least parts of the first inspection region (pattern A of sample [55 of figure 1]);

scanning (56 of figure 1) the second inspection region (figures 1, 22, and 23A-23B) to the first direction (e.g., Y direction in figure 23B) using the imaging device (57 of figure 1) to obtain a second measurement pattern (e.g., A of figure 1) representing at least parts of the second inspection region (pattern A of sample [55 of figure 1]);

comparing (60 of figure 1) the first measurement pattern and the second measurement pattern with each other with a comparator circuit (60 of figure 1) to determine presence or absence of a defect formed on the sample (figure 1); and

controlling a scanning condition (e.g., a positioning circuit [207 of figure 22] coupled to a CPU [210 of figure 22]) for scanning a pattern of the second inspection region by the imaging device (57 of figure 1 or 205 of figure 22) and a laser measuring stsystem (figure 22) so as to keep the same with the scanning condition when the pattern of the first inspection region is scanned by the imaging device (col.4 line 57 to col.60 and abstract). Figures 1-32.

Regarding claims 9; Isomura et al discloses a pattern inspecting apparatus comprising:

an emitting unit (e.g., a light source [203 of figure 22]) configure to emit to a sample (201 of figure 22) having a first inspection region on which a first pattern is

Art Unit: 2886

formed and a second inspection region on which a second pattern is formed (figures 23A-23B, 24, and 25A-25B);

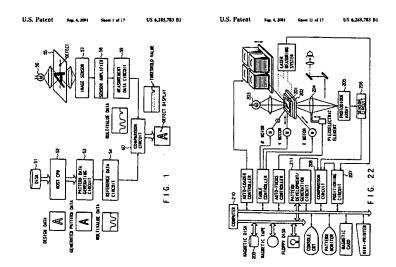
an imaging device (205, 206 of figure 22) that have detecting unit ( 206 of figure 22) that detect images from the samples (201 of figure 22);

a position recognizing unit (e.g., a positioning circuit [207 of figure 22]) configure to recognize a position of the sample (201 of figure 22) with respect to the detecting unit (206 of figure 22) and a laser measuring system (figure 22);

a signal output unit (e.g., a table control circuit [figure 22], autofocus control circuit [figure 22], and generation circuit [211 of figure 22]) configure to output a signal to output a relative signal according to a relative movement between the sample (201 of figure 22) and the detecting unit (205, 206 of figure 22); and

a control unit (e.g., a CPU [210 of figure 22) configure to control a scanning condition (e.g., a positioning circuit [207 of figure 22] coupled to a CPU [210 of figure 22]) for scanning a pattern of the second inspection region by the imaging device (57 of figure 1 or 205 of figure 22) and a laser measuring system (figure 22) so as to keep the same with the scanning condition when the pattern of the first inspection region is scanned by the imaging device (col.4 line 57 to col.60 and abstract). Figures 1-32.

Art Unit: 2886



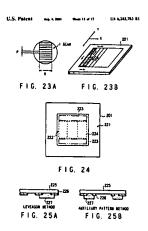
Regarding claim 2; Isomura et al discloses the scanning condition is a positional relationship of pixels of the imaging device (57 of figure 1) and the pattern of the first or second inspection region (A of figure 1 and 4).

Regarding claim 3; Isomura et al discloses the pattern is an edge of the first or second inspection region (figures 23A-23B and 24).

Regarding claims 4 and 10; Isomura et al discloses the pixels of the imaging device(205, 206 of figure 22) is arranged in a line which is orthogonal to the first direction ( X, Y of figures 23A-23B).

Regarding claim 5; Isomura et al discloses the first measurement pattern contains a plurality of first image portions in the first inspection region, and the second measurement pattern contains a plurality of second image portions in the second inspection region. (figures 23A-23B and 24)

Art Unit: 2886



Regarding claims 6 and 14; Isomura et al discloses further comprising:
generating reference pattern data (figure 1) corresponding to the measurement pattern
data (figure 1) from design data (figure 1) used when a pattern is formed on the sample
(55 of figure 1); and comparing (60 of figure 1) the first and second measurement
pattern data and the reference pattern data (figure 1) with each other to determine
presence or absence of a defect of the pattern formed on the sample (figure 1 and
abstract).

Regarding claims 7-8 and 13; Isomura et al discloses further comprising: a pattern memory (115 of figure 10) for storing a positional relationship of pixels of the imaging device (57 of figure 1) and the edge of the first inspection region (X, Y, L1, L2 of figure 10) when the edge of the first inspection region is scanned, wherein the step of storing stores a positional difference between the edge of the first inspection region (X, Y, L1, L2 of figure 10) and the pixel of the imaging device (57 of figure 1) as the positional relationship.

Art Unit: 2886

Regarding claims 11-12; Isomura et al discloses the emitting unit (203 of figure 22) configure to emit one of a light beam and an electron beam and imaging device (57 of figure 1) for detecting one of reflection light, transmission light, and a secondary electron.

Regarding claims 15-16; Isomura et al discloses the signal output unit outputs the relative signal on a predetermined timing (figure 1 as indicate multivalue data and threshold value) while the detecting unit detects one of the reflection light, the transmission light (from sample 55 of figure 1) and the secondary electron from the first and second inspection regions.

Regarding claims 17; Isomura et al discloses the signal output unit outputs the relative signal whenever the sample (55 of figure 1 or 201 of figure 22) moves by a predetermined distance (figure 1 and 22) relatively with respect to the detecting unit (57 of figure 1 or 205, 206 of figure 22).

### Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Sawa et al (6965687) discloses Size checking method and apparatus; Tsuchiya et al (6883160) discloses pattern inspection apparatus; Kuwabara (6229331) discloses apparatus for and method of inspecting patterns on semiconductor integrated devices; Tabata et al (5602645) discloses pattern evaluation apparatus and a method of pattern evaluation; or Tojo et al (5404410) discloses method and system for generating a bit pattern.

Application/Control Number: 10/743,830 Page 9

Art Unit: 2886

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sang Nguyen whose telephone number is (571) 272-2425. The examiner can normally be reached on 9:30 am to 7:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tarifu Chowdhury can be reached on (571) 272-2800 ext. 86. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

June 22, 2007

Sang H/Nguyen Primary Patent Examiner Art Unit 2886